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Love Wave Sensor Based on Thin Film Molecularly Imprinted Polymer: Study of VOCs adsorption
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Professor Marcelo Antonio Pavanello, Editor
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FOREWORD

In this issue of JICS some of the papers have been selected from the presented at SBMicro2013 (28th Symposium on Microelectronics Technology and Devices), which has been held in Curitiba, Brazil, in 2013. Among the contributions presented at the Symposium, only a few best rated were selected by the JICS Editorial Board and have been invited to submit an extended version to the Journal. These extended papers have passed through the usual reviewing process before acceptance. In addition to the best papers presented at the conference, spontaneous submissions passed through the usual reviewing process and have been accepted as regular papers.

We would like to thank the authors for their effort in preparing these high quality papers, as well as the reviewers for their valuable contribution on paper evaluation and selection, which guarantees the scientific level of this issue. We sincerely hope that JICS readers will enjoy these contributions.

Marcelo Antonio Pavanello
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